

	<b>S arch Text</b>
<b>1</b>	<b>(250/492.1,492.23,492.3).CCLS.</b>
<b>2</b>	<b>((250/492.1,492.23,492.3).CCLS.) and (microlithography)</b>
<b>3</b>	<b>((250/492.1,492.23,492.3).CCLS.) and (microlithography or lithography)</b>
<b>4</b>	<b>((250/492.1,492.23,492.3).CCLS.) and (microlithography or lithography)) and projection</b>
<b>5</b>	<b>((250/492.1,492.23,492.3).CCLS.) and (microlithography or lithography)) and projection) and scattering</b>
<b>6</b>	<b>(reticle or mask) with ((high or low) adj scattering)</b>
<b>7</b>	<b>((US "6573515" B1 US "6492647" B1 US "6335127" B1 US "6232040" B1 US "6151101" A US "5674413" A).pn. ) and projection</b>
<b>8</b>	<b>(charged adj particle) and (lithography or microlithography) and (scattering with (mask or reticle)) and ((cutoff or (cut adj off)) adj plate)</b>
<b>9</b>	<b>(charged adj particle) and (lithography or microlithography) and ((cutoff or (cut adj off)) adj plate)</b>
<b>10</b>	<b>((US "6573515" B1 US "6492647" B1 US "6335127" B1 US "6232040" B1 US "6151101" A US "5674413" A).pn.)</b>

	<b>Search Text</b>
<b>11</b>	<b>(430/5,22,30,296).CCLS.</b>
<b>12</b>	<b>(reticle or mask) with scattering and ((430/5,22,30,296).CCLS.)</b>
<b>13</b>	<b>(charged adj particle) and ((reticle or mask) with scattering and ((430/5,22,30,296).CCLS.))</b>
<b>14</b>	<b>((charged adj particle) and ((reticle or mask) with scattering and ((430/5,22,30,296).CCLS.))) and projection</b>
<b>15</b>	<b>("5130213").PN.</b>
<b>16</b>	<b>wo-9105360\$.did. or 5200819.pn.</b>
<b>17</b>	<b>wo-9105360\$.did.</b>
<b>18</b>	<b>wo-9105360\$.did.</b>
<b>19</b>	<b>holograhic adj filter</b>
<b>20</b>	<b>holographic adj filter</b>
<b>21</b>	<b>immunosuppressive adj drug</b>
<b>22</b>	<b>(antiproliferative adj agents) or compounds or inhibitors</b>
<b>23</b>	<b>(immunosuppressive adj drug) and ((antiproliferative adj agents) or compounds or inhibitors )</b>